

(19) World Intellectual Property  
Organization  
International Bureau



(43) International Publication Date  
1 September 2005 (01.09.2005)

PCT

(10) International Publication Number  
**WO 2005/081592 A1**

(51) International Patent Classification<sup>7</sup>: **H05H 01/02**

(21) International Application Number:  
PCT/AU2005/000227

(22) International Filing Date: 21 February 2005 (21.02.2005)

(25) Filing Language: English

(26) Publication Language: English

(30) Priority Data:  
2004900864 20 February 2004 (20.02.2004) AU

(71) Applicant (for all designated States except US): **THE UNIVERSITY OF SYDNEY** [AU/AU]; Parramatta Road, Sydney, New South Wales 2006 (AU).

(72) Inventors; and

(75) Inventors/Applicants (for US only): **YIN, Yongbai** [AU/AU]; c/- The University of Sydney, Parramatta Road, Sydney, New South Wales 2006 (AU). **BILEK, Marcela** [AU/AU]; c/- The University of Sydney, Parramatta Road,

Sydney, New South Wales 2006 (AU). **MCKENZIE, David** [AU/AU]; c/- The University of Sydney, Parramatta Road, Sydney, New South Wales 2006 (AU). **IMENES, Anne, Gerd** [NO/AU]; c/- The University of Sydney, Parramatta Road, Sydney, New South Wales 2006 (AU).

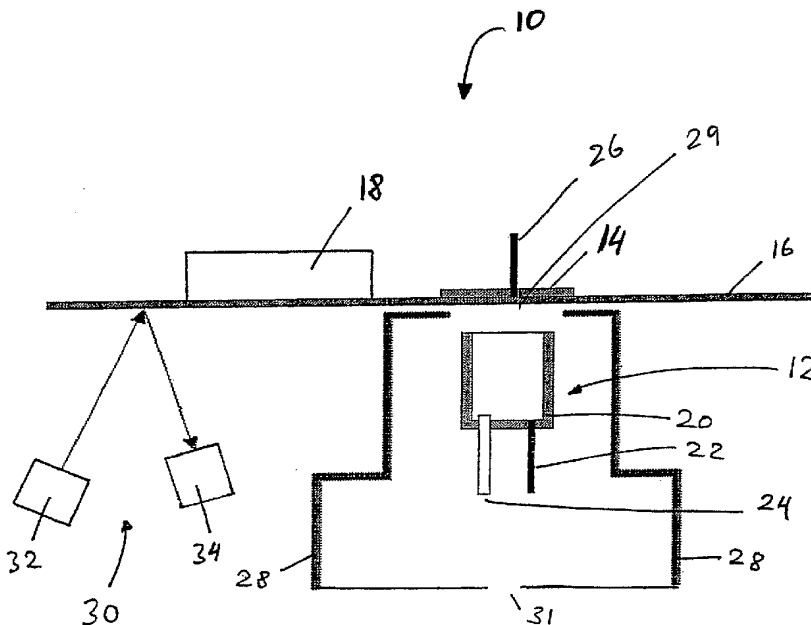
(74) Agent: **GRIFFITH HACK**; Level 6, 256 Adelaide Terrace, Perth, Western Australia 6000 (AU).

(81) Designated States (unless otherwise indicated, for every kind of national protection available): AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NA, NI, NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SY, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW.

(84) Designated States (unless otherwise indicated, for every kind of regional protection available): ARIPO (BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW), Eurasian (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM),

[Continued on next page]

(54) Title: AN APPARATUS FOR PLASMA TREATMENT



(57) Abstract: The present invention provides an apparatus (10) for plasma treatment of a substrate surface (16). The apparatus comprises a plasma source (12) for generating a plasma and a plasma-control electrode (14). The apparatus further comprises a drive means for effecting a relative movement between the plasma-control electrode (14) and the plasma source (12) or of the plasma-control electrode (14) and the plasma source (12) relative to the substrate (16). The plasma-control electrode (14) is located adjacent the substrate (16) to facilitate treatment of the substrate surface (16) in a controlled manner.



European (AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IS, IT, LT, LU, MC, NL, PL, PT, RO, SE, SI, SK, TR), OAPI (BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG).

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**Published:**

— *with international search report*